Attorney Docket No.: 0180146

PATENT APPLICATION COVER SHEET

COMMISSIONER FOR PATENTS P.O. BOX 1450 ALEXANDRIA, VA 22313-1450

Sir/Madam:



22388 U.S.PTO 10/678445

Transmitted herewith is the patent application of:

Inventor(s): George Jonathan Kluth, Joong S. Jeon, Qi Xiang and Huicai Zhong

For: "Method for Forming Polysilicon Gate on High-K Dielectric and Related Structure"

	This application is a Continuation	□ Divisional	☐ Continuation-in-part (CIP)	of prior application
Nο	•		-	

Enclosed are:

- □ Three (3) Sheets of drawings
- □ Request for Non-Publication (Form PTO/SB/35 (11-00))
- An assignment of the invention to <u>Advanced Micro Devices</u>, <u>Inc.</u>
- ☐ The enclosed payment includes \$40.00 for the recording of the assignment
- ☐ Applicant(s) claim(s) small entity status
- ☐ Information Disclosure Statement
- ☐ Preliminary Amendment
- □ Declaration and Power of Attorney
- ☐ The filing fee has been calculated as shown below:

	(Col. 1)	(Col. 2)
FOR:	No. Filed	No. Extra
BASIC FEE		
TOTAL CLAIMS	20 -20 =	0
INDEPENDENT CLAIMS	3 -3=	0
MULTIPLE DEPENDENT CLAIMS PRESENTED		

If the difference in Col. 1 is less than zero, enter "0" in Col. 2

SMALL ENTITY

RATE	FEE
	\$385.00
x 9 =	\$
x 43=	\$
+145=	\$
TOTAL	\$

OTHER THAN A SMALL ENTITY

SWIALL LIVITI		
RATE	FEE	
	\$770.00	
x \$6 =	\$0.00	
x 86 =	\$0.00	
+290 =	\$	
TOTAL	\$770.00	

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×	Enclosed is a payment in the amount of \$810.00 by credit card (Form PTO-2038 attached).		
	Please charge Deposit Account No. 50-0731 in the amount of \$		
⊠	The Commissioner is hereby authorized to charge payment of any additional fees associated with this communication, or credit any overpayment to Deposit Account No. 50-0731. A duplicate copy of this sheet is enclosed.		
Date:	10/3/03	MICHAEL FARJAMI, ESQ. Reg. No.: 38,135	
P	25700 PATENT TRADEMARK OFFICE	"EXPRESS MAIL" mailing label number	
FARJA 16148 S Irvine,	l Farjami, Esq. MI & FARJAMI LLP Sand Canyon CA 92618 84-4600	(Signature) Lori Llave (Typed or Printed Name of Person Mailing Paper or Fee)	

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NONPUBLICATION REQUEST UNDER 35 U.S.C. 122(b)(2)(B)(i)

First Named Inventor		Kluth, et al.	
Title	Method for Forming Polysilicon Gate on High- K Dielectric and Related Structure		
Atty Docket Number		0180146	

I hereby certify that the invention disclosed in the attached application has not and will not be the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing.

I hereby request that the attached application not be published under 35 U.S.C. 122(b).

10/3/03 Date Signature

Michael Farjami, Esq.
Typed or printed name

This request must be signed in compliance with 37 CFR 1.33(b) and submitted with the application **upon filing.**

Applicant may rescind this nonpublication request at any time. If applicant rescinds a request that an application not be published under 35 U.S.C. 122(b), the application will be scheduled for publication at eighteen months from the earliest claimed filing date for which a benefit is claimed.

If applicant subsequently files an application directed to the invention disclosed in the attached application in another country, or under a multilateral international agreement, that requires publication of applications eighteen months after filing, the applicant **must** notify the United States Patent and Trademark Office of such filing within forty-five (45) days after the date of the filing of such foreign or international application. **Failure to do so will result in abandonment f this application (35 U.S.C. 122(b)(2)(B)(iii)).**